Notice of Allowability		Application No.	Applicant(s)
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Our Copies of the certified copies of the priority documents have been received in this patients.			
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5. A SUBSTITUTE O INFORMAL PATE 6. CORRECTED DR/ (a) including char 1) hereto (b) including chan Paper No./Mai Identifying indicia such each sheet. Replaceme 7. DEPOSIT OF and	MONTHS FROM THE "MAILING DATE" to timely comply will result in ABANDONM PERIOD IS NOT EXTENDABLE. ATH OR DECLARATION must be submit APPLICATION (PTO-152) which give AWINGS (as "replacement sheets") must ges required by the Nötice of Draftsperson or 2) to Paper No./Mail Date ges required by the attached Examiner's I Date sthe application number (see 37 CFR 1.6 int sheet(s) should be labeled as such in the More INFORMATION about the deposts comment regarding REQUIREMENT F	itted. Note the attached EXAMINER'S es reason(s) why the oath or declaration to be submitted on's Patent Drawing Review (PTO-9 Amendment / Comment or in the Off 34(c)) should be written on the drawing e header according to 37 CFR 1.121(d).	S AMENDMENT or NOTICE OF ion is deficient. 48) attached lice action of sin the front (not the back) of
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1. Notice of References	Cited (PTO-892)	5. Notice of Informal Pate	ent Application (PTO 152)
	's Patent Drawing Review (PTO-948)	6. 🔲 Interview Summary (P	TO-413)
' MPCI NO./IVIAII DAIE	re Statements (PTO-1449 or PTO/SB/08)	Paper No./Mail Date _ 7. ⊠ Examiner's Amendmen	
of Biological Material	Regarding Requirement for Deposit	8. ☑ Examiner's Statement 9. ☐ Other	of Reasons for Allowance
U.S. Patent and Trademark Office		F	M. Wilczewski Primary Examiner Fech Center 2800

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EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

This application is in condition for allowance except for the presence of claims 11-19 drawn to an invention non-elected without traverse. Accordingly, claims 11-19 have been cancelled.

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: It is well known in the art to form an insulating layer on the sidewalls of a bump electrode to prevent an electrical short through the side surface of the electrode which occurs due to a conductive elements or balls in ACA/ACF thereby yielding a plurality of metal bumps having sidewalls covered with an insulating layer, see, for example, Kim, U.S. Patent 6,232,563, of record or Chun, U.S. Patent 5,923,080, newly cited. However, Chun teaches to form the insulating layer on the entire outer surface of the electrode (see Figure 3; column 2, lines 59-61; and column 2, line 66, bridging column 3 to line 8). Kim et al. teach to form the insulating layer only on the side surfaces of each bump electrode (see column 3, lines 55-67; column 4, lines 47-62; column 4, line 66, bridging column 5 to line 32; and figures 4, 58-5D and 6A-6B). Hence the structures of both Kim and

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Chun comprise a plurality of metal bumps in which adjacent sidewalls of the bumps are covered with an insulating layer. None of the prior art of record teaches or suggests a structure comprising a plurality of metal bumps wherein the sidewall of a first bump is covered with an insulating layer but the adjacent sidewall of a second bump is not covered by an insulating layer, as presently claimed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication should be directed to M. Wilczewski at telephone number (571) 272-1849.

M. Wilczewski Primary Examiner Tech Center 2800